3-10-0-

PATENT 790001-2036 IFCD



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Tomoaki SHINO

Serial No.

10/661,906

For

SEMICONDUCTOR DEVICE FORMED IN

SEMICONDUCTOR LAYER ON INSULATING

FILM

Filed

September 12, 2003

Examiner

Smoot, Stephen W.

Art Unit

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AMENDMENT

Mail Stop Amendment Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed December 14, 2004, please amend the above-identified application as follows.

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